# United Technologies Research Center

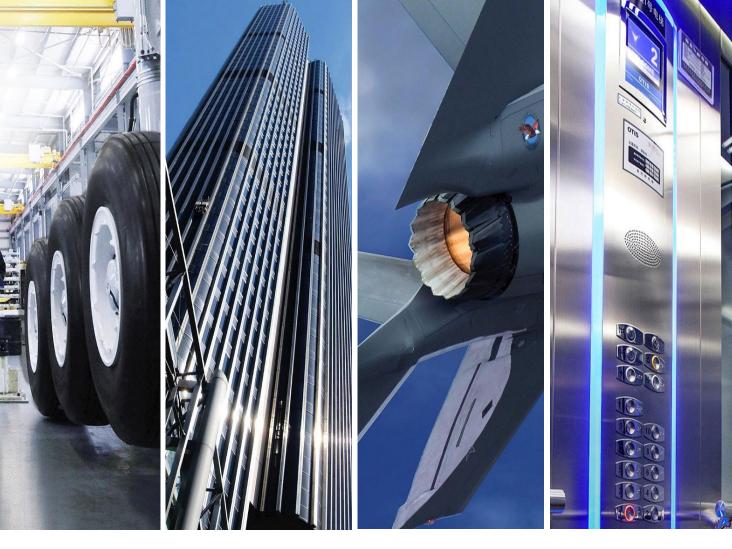
Nanosensor Manufacturing Workshop

Presented by Sameh Dardona Principle Research Engineer

June 13, 2017

















# United Technologies Research Center



#### Cork, Ireland

Established in 2010, focuses on energy, security and aerospace systems



Established in 1997, focuses on integrated buildings, fluid and mechanical systems

#### Berkeley, CA

Established in 2009, focuses on cyber physical systems and embedded intelligence

#### East Hartford, CT

Founded in 1929, focuses on a broad range of system engineering, thermal, fluid, material, and informational sciences Rome, Italy

Joined UTC in 2012, focuses on model-based design and embedded systems engineering

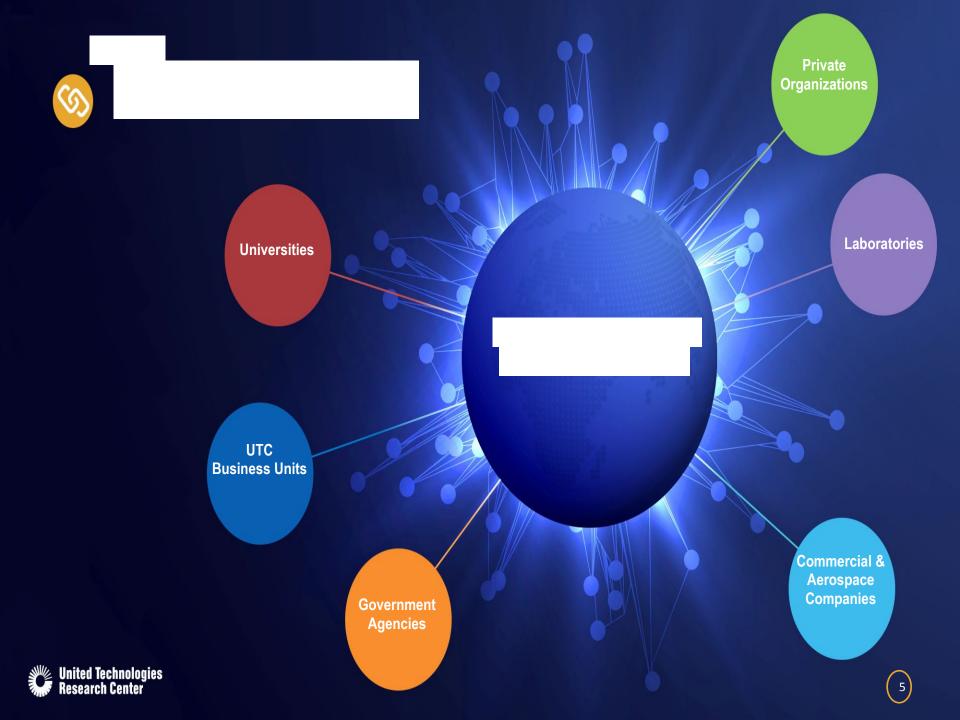


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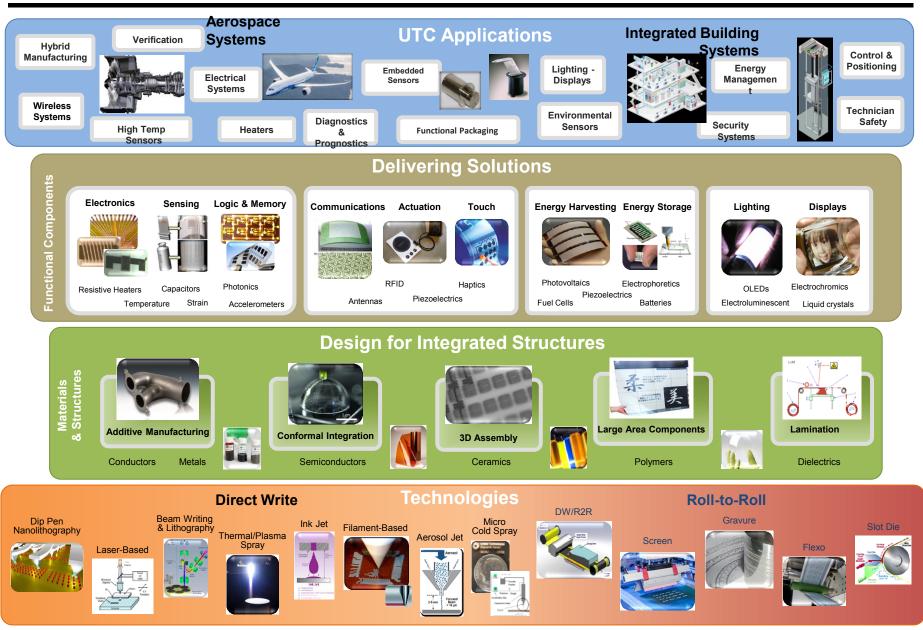
# cutting edge

Advanced Manufacturing Aerodynamics & Acoustics Applied Mechanics Autonomy & Controls Combustion Cyber Physical Security Data Science Embedded Intelligence Materials Networks & Communications Power Electronics Thermal Management

United Technologies Research Center



#### DIRECT WRITE AND PRINTED ELECTRONICS



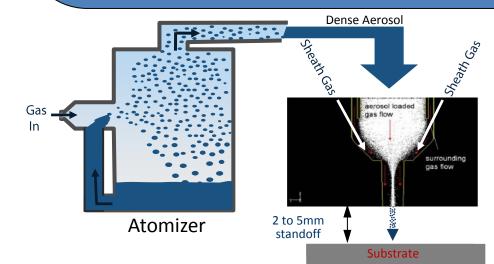
## **Sensors Manufacturing at UTRC**

#### Multi-head Aerosol Jet System by Optomec

Fine Feature Print Head (trace width 15µm-300µm) Laser Cure (1 W @ 700 nm)



Plasma Head (Air, N<sub>2</sub>, Ar, O<sub>2</sub>, H<sub>2</sub>, etc.) Wide Nozzle Print Head (trace width 0.3-3 mm)



#### Key benefits

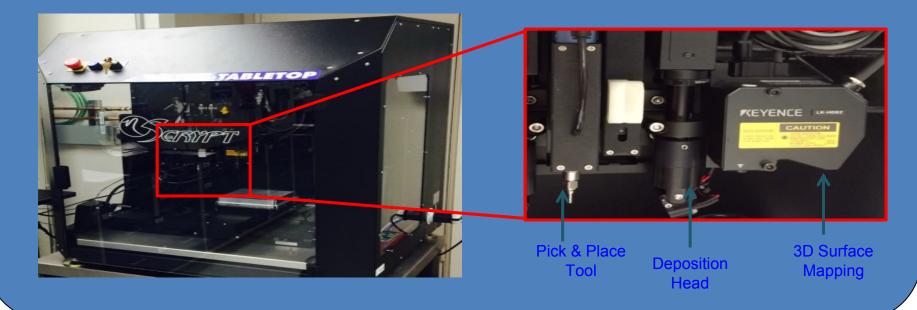
Widest range of working distances and line widths coaxial laser treatment

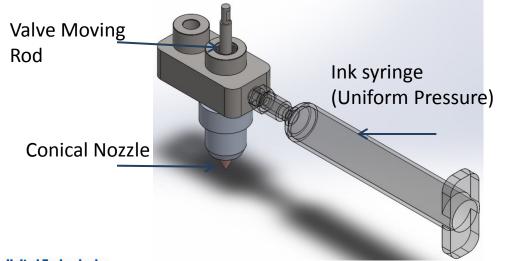
#### Key drawbacks

Complex apparatus Requires inks which can be aerosolized

## **Direct Write Manufacturing of Micro/Nano Sensors**

#### Multi-head Dispensing System by nScrypt





#### Key benefits

Greatest range of viscosities, simplicity, capable of 3D lattice structures

#### Key drawbacks

Knowledge of surface topography needed to maintain constant stand-off distance

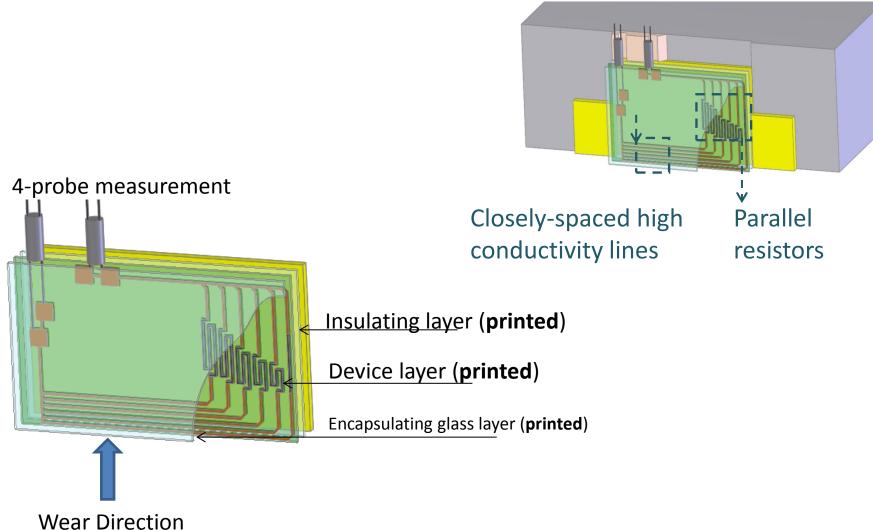


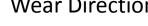
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## **Wear Sensing Concept**

#### **Embedded Wear Sensor**







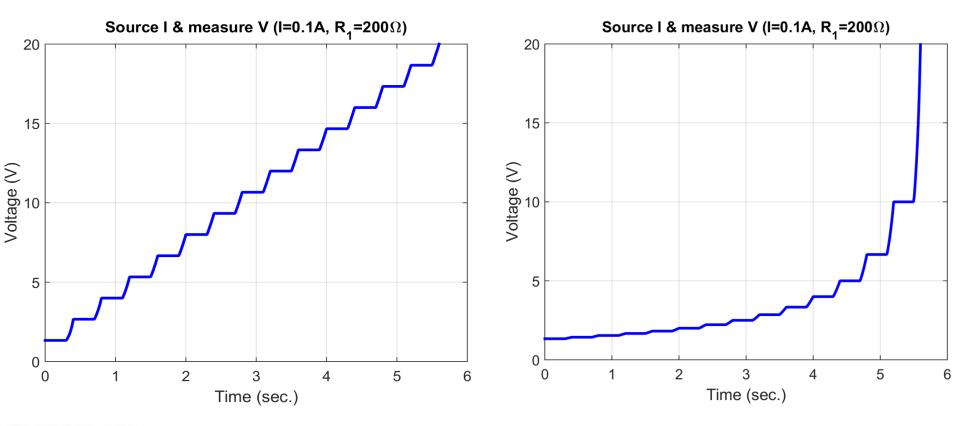
## **Device Circuit Design & Simulation**

#### **Unequal Value Resistors**

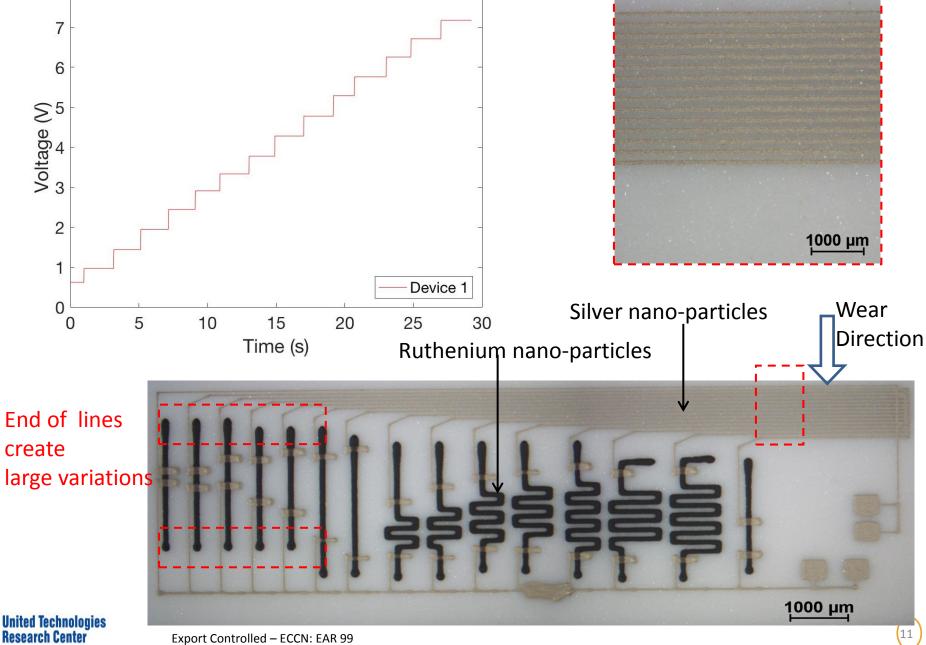
- 1) Equal changes in voltage as blade rubs the coating 1) Small change in voltage as blade initially rubs
- 2) Change in voltage is higher than noise level
- 3) Broad range of resistor values needed

#### Equal Value Resistors

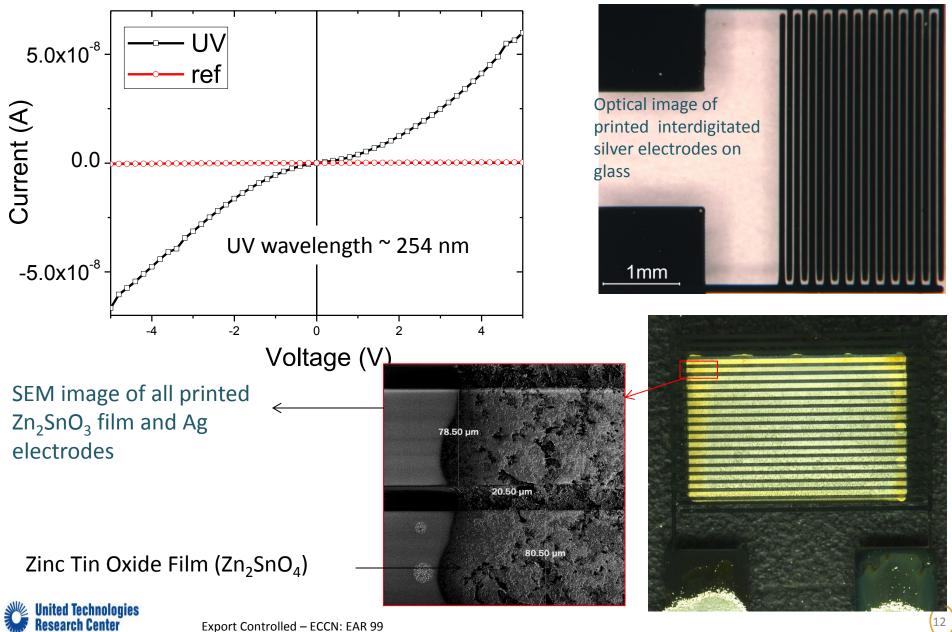
- COating 1) Small change in voltage as blade initially rubs the coating
  - 2) Some of the voltage changes could be below the noise level during operation ( high temperature)



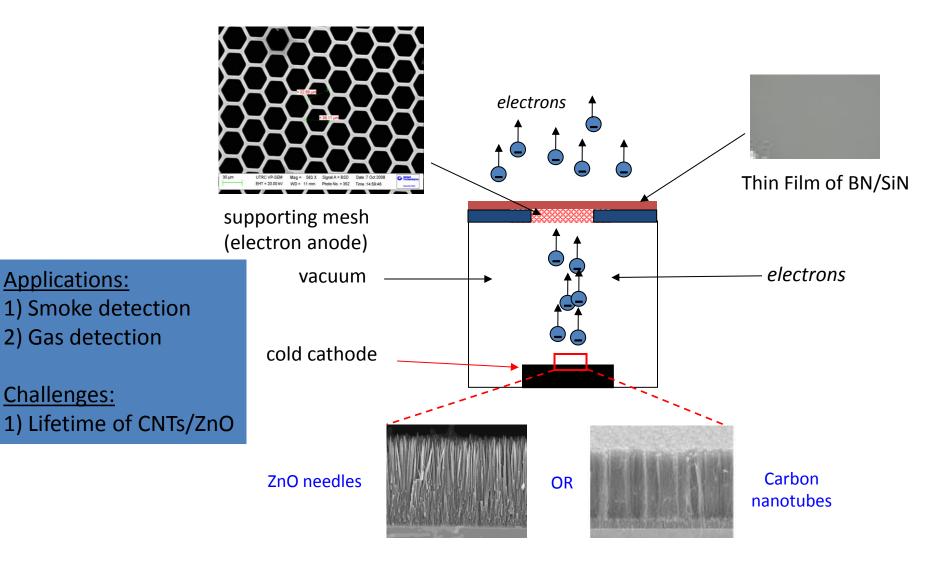
## Wear Sensor Design & Manufacturing



## **Printed Photoconductive Flame Detector**



## Low Energy Electron Source (non-radioactive)





## **NextFlex Overview**

<u>NextFlex</u> is a public-private consortium of companies, academic institutions, nonprofits and governments with a mission to advance US manufacturing of flexible-hybrid electronics.

\$50K membership fee\$50K in-kind contributionTechnical council seat (1 vote)Governing council (1/3 vote)

## **Proposal Activities**

- Project call 1.0 12/2015
- Project call 2.0 04/2016
- Project call 3.0 05/2017

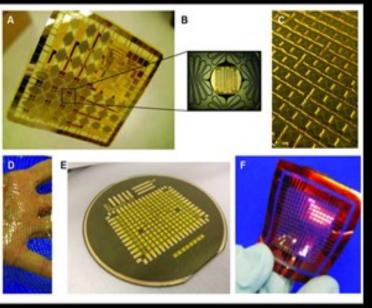
#### Membership (www.nextflex.us)

ademic	CORPORATE	ACADEMIC & NON-PROFI
to f	Tier 1	Tier 1
	The Boeing Company*	Auburn Univesity*
		Binghamton University*
	Tier 2	Georgia Institute of Technology*
	Brewer Science, Inc*	University of Massachusetts Lowell*
	Eastman Chemical Co*	University of Texas at Austin*
	DuPont	
	General Electric Company	Tier 2
	United Technologies Research Center	Purdue University*
		University of Arizona*
	Tier 3	University of Connecticut*
	Acellent Technologies Inc.*	University of Washington*
	American Semiconductor, Inc.*	Washington State University*
	Custom Electronics, Inc.*	Western Michigan University*
	E Ink Corporation*	
	Jabil*	Tier 3
	Molex, LLC*	University of Arkansas*
	On Semiconductor*	California Polytechnic State University
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### **Distributed and Stretchable Hybrid Asset Monitoring Platform**

DEVELOPMENT, MATURATION, TESTING



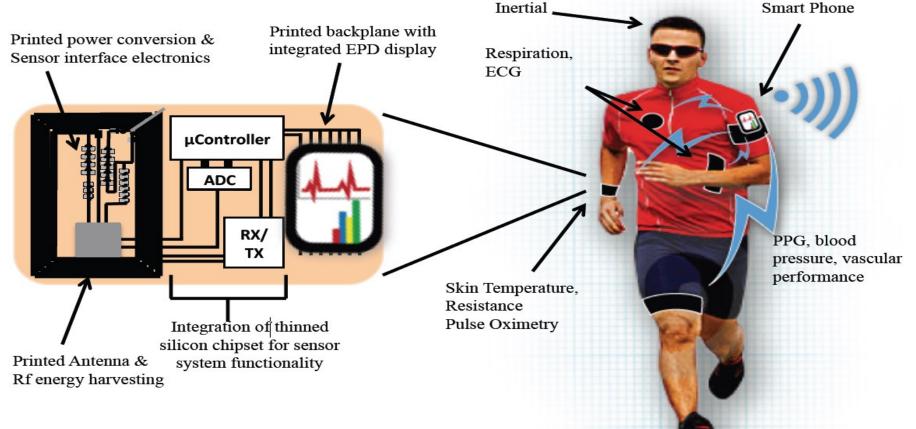
# SCALE-UP, FULL-SCALE TESTING IMPLEMENTATION RTD, Neuro-chips

#### **Overall Objectives**

- Improve reliability and robustness of sensor nodes and wires using CMOS manufacturing
- Identify and develop pick and place technology
- Tooling for uniform and in-plane stretching and handling of substrates
- Integration and implementation of sensor network qualification tool into manufacturing process
- A demonstrator prototype of value to industry



# Scalable Manufacturing for a Wearable, Integrated Human Performance Monitoring System



**Demonstrate a Human Performance Monitoring Platform (HPM)** consisting of pulse oximeter and heart rate sensors printed on flexible substrates integrated with conductive trace interconnects. Demonstrator includes integrated power management with energy harvesting, low energy Bluetooth (BLE) with printed antenna architecture, and low-power display and display controller electronic sub-systems.



#### **THANK YOU**

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